



Beam Initiative

The Fine Line: Autumn 2016 Videos for the eBeam Community

Shot Talk

Aki Fujimura, CEO of D2S, highlights several key developments at BACUS, including the eBeam Initiative Perception and Mask Maker surveys, recent updates on multi-beam mask writing and EUV, and a new generation of D2S GPU-acceleration solutions for semiconductor and photomask design and manufacturing. A Japanese version of the video can be found [here](#).



Leo Pang, chief product officer of D2S, also recaps these developments in [Chinese](#).



Tech Talk

Dr. David Lam, Chairman of Multibeam Corp., explains how eBeam technology can create the foundation for a more secure connected world by enabling IC-embedded security for Internet of Things (IoT) devices.



Perspectives

eBeam industry luminary Brian Grenon offers an analysis of the results of the eBeam Initiative's second annual Mask Maker survey—including surprising findings on average data volumes, write times and turn-around times.



Video Archive

The Fine Line: Summer 2016 Edition



Shot Talk:
[Aki Fujimura, D2S](#)



Shot Talk:
[Leo Pang, D2S](#)



Tech Talk:
[Naoya Hayashi, DNP](#)



Perspectives:
[Aki Fujimura, D2S](#)

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The eBeam Initiative provides a forum for educational and promotional activities regarding new semiconductor manufacturing approaches based on electron beam (eBeam) technologies. Its goals are to reduce the barriers to adoption to enable more integrated circuit (IC) design starts and faster time-to-market while increasing the investment in eBeam technologies throughout the semiconductor ecosystem. For more information, please email requests@ebeam.org or visit www.ebeam.org